

**Electronic Filing System (EFS) Data  
Electronic Patent Application Submission  
USPTO Use Only**

EFS ID: 60295  
Application ID: 10709406   
Title of Invention: METHOD TO REDUCE  
PHOTORESIST PATTERN  
COLLAPSE BY CONTROLLED  
SURFACE MICROROUGHENING  
First Named Inventor: Colin Brodsky  
Domestic/Foreign Application: Domestic Application  
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FEE RECORD SHEET

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